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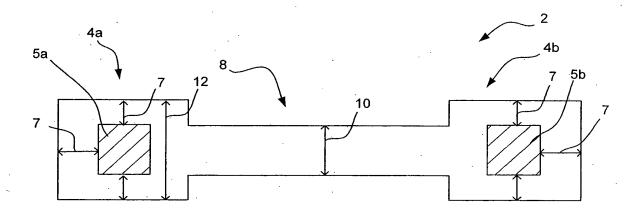


FIG. 1

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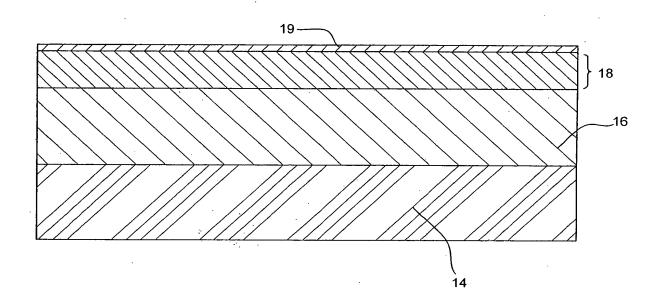


FIG. 2

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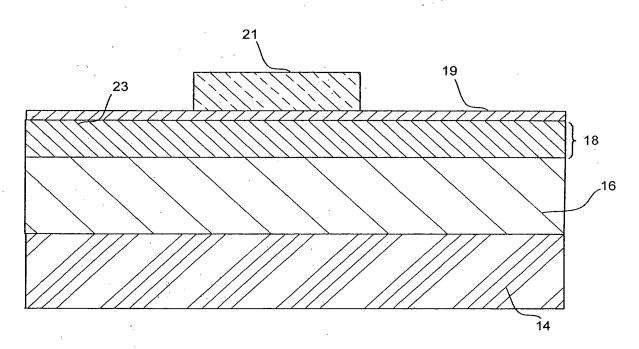
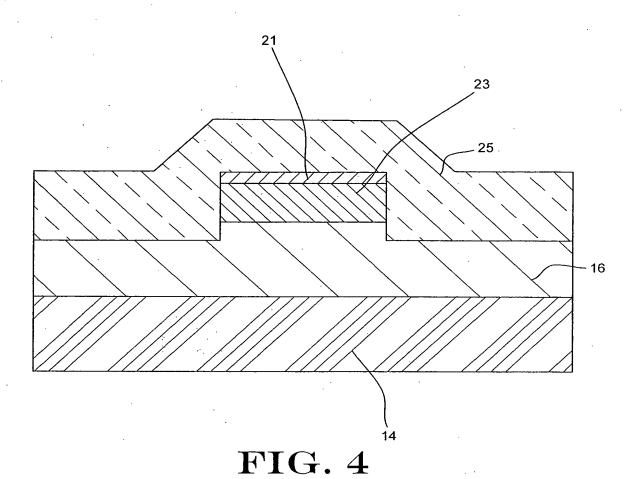


FIG. 3

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METHOD FOR MANUFACTURE OF MAGNETO-RESISTIVE BIT STRUCTURE Liu et al. Appl. No.: Unknown Atty Docket: MICRON.230C1

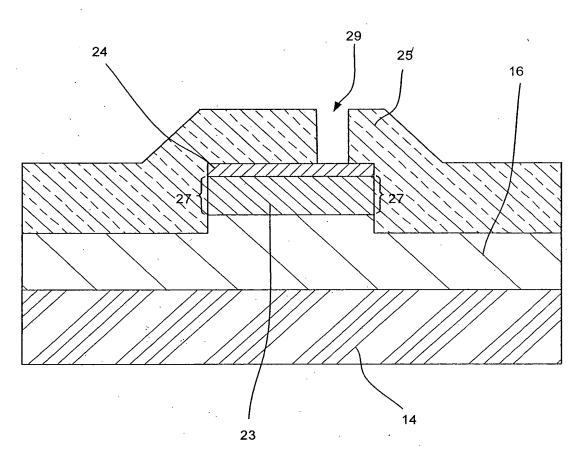


FIG. 5

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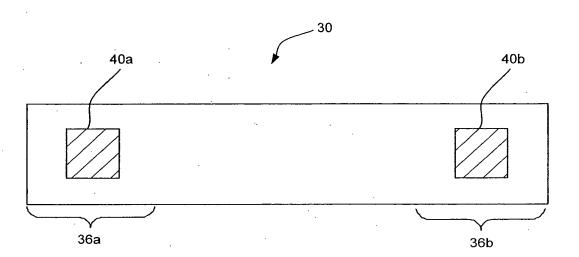


FIG. 6